

## **Thursday 20 June**

09:00

## Session 1 - Fundamental understanding - General

Session | Location: Ferrara, Italy

09:00-09:30

Application runs the show: what can we learn about the future from the past?

Speaker

Dr Nicolae Barsan

09:30-09:50

Monitoring Surface Stoichiometry, Work Function and Valance Band of Tungsten Oxide (WO3), Molybdenum Oxide (MoO3) and Tin Oxide (SnO2) Thin Films as a Function of Temperature and Oxygen Partial Pressure with Advanced Surface Sensitive Techniques for Chemical Sensing Applications

Speaker

Dr Ciftyurek Engin

09:50-10:10 How the gas flow affects conductometric sensor performance

Speaker

Dr Gemma G. Mandayo

10:10-10:30

Heterogeneous integration of metal oxides - towards a CMOS based multi gas sensor device

Speaker

Anton Koeck

10:30-10:50

Consideration for oxygen adsorption species on SnO2 semiconductor gas sensors

Speaker

Prof. Kengo Shimanoe

10:50